

THE CHINESE UNIVERSITY OF HONG KONG Department of Physics COLLOQUIUM

## Symmetry Indicators for Topological Materials

by

Dr. Hoi Chun Adrian PO (傅凱駿博士) Department of Physics Massachusetts Institute of Technology, USA

Date: May 22, 2020 (Friday) Time: 4:00 - 5:00 p.m. Join ZOOM Meeting: <u>https://cuhk.zoom.us/j/94003130202</u>



## Abstract

Topological materials are characterized by robust physical signatures, like anomalous surface states, that are derived from the topological distinction between their ground states and those of their conventional counterparts. The research in these quantum materials has led to a new paradigm in condensed matter physics in which the synergy between topology, symmetry, and quantum entanglement plays a key role in our physical description of the systems. In this talk, we will focus on how this paradigm shift has enabled a modernization of the nine-decade old theory of electronic band structures, and how this modern perspective is well-suited for the efficient discovery of topological materials including insulators, semimetals, as well as superconductors.

